

ABSTRACT OF THE DISCLOSURE

A substrate includes fine lines. The fine lines are obtained according to a fine-line forming process, which includes a process of projecting light

5 from above the substrate onto predetermined regions on a photosensitive material provided on the substrate and a developing process after the light projection process. A narrow-width portion is provided at an end portion of each of the fine lines in a longitudinal direction of the fine line. The width of the narrow-width portion is smaller than the width of a portion adjacent to

10 the narrow-width portion.

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